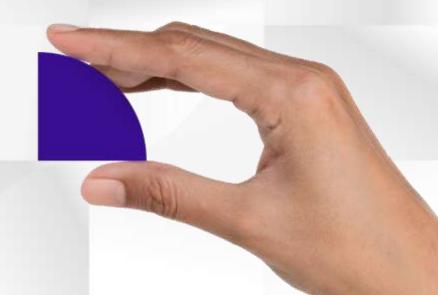
Scientific Expertise Beneficial to Business

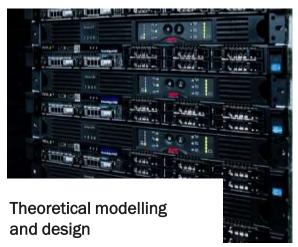


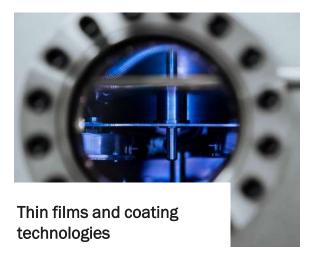
40 Years of Expertise





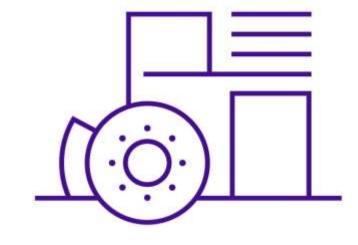






Our offer

Innovation, technology and product development R&D services, testing & characterization Prototyping and small-scale production Industrialization up-scaling services



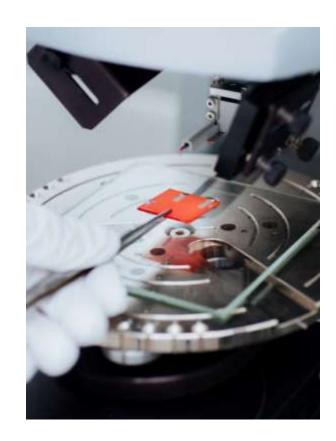
Together with our industrial partners

- EuroLCDs thin films and coatings with LCD
- Sidrabe vacuum coating devices, upscaling
- GroGlass anti reflective glass
- Schaeffler in-line coatings systems, antifiction, hardening and other coatings
- Baltic Scientific Instruments radiation sensors and spectrometers
- RD Alfa MD radiation resistant microelectronics
- CeramOptec, Light Guide Optics custom made fiber optic components and products

Thin films and coatings

Thin films and coatings

- Thin films and coatings tuned for your applications:
 - photonics
 - sensors
 - batteries
 - catalysts
- Practically any materials and wide range of methods
- On time, flexible and customized process for client
- 40 experts in the field



Tools and tecniques

- Thin film deposition cluster
- Magnetron sputtering complex
- Thermal evaporation cluster
- Plasma electrolytic oxidation
- Wet casting of materials
- Inhouse lithography technologies and characterization services



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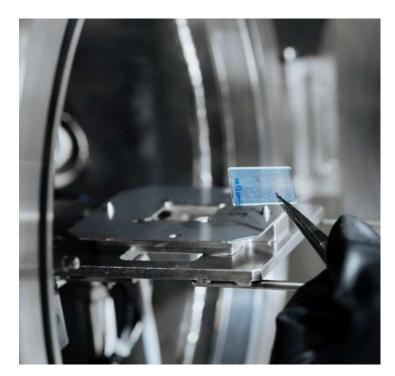
Thin film deposition cluster tool

- In ISO 7 cleanroom environment
- Highly customizable
- Magnetron sputtering (2 chambers)
 - DC, Pulsed-DC, RF, HiPIMS
- Low temperature evaporation
- High temperature evaporation
- E-beam evaporation



Thin film deposition cluster tool

- Various substrates (metal, glass, plastic, ceramic) with standard size 50x50x5mm
- Ar and oxygen plasma pre-treatment for substrate cleaning
- Contact and contactless heating and cooling
- Multi-layer stacks without venting
- Uniformity due to substrate rotation
- Thickness measurement (for evaporation)
- Base pressure 10⁻⁷ mbar
- Glovebox loading/unloading



Magnetron sputtering complex

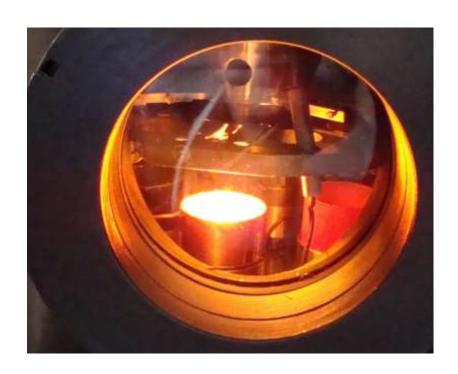
- Two magnetron systems (DC, pulsed DC, RF, HiPIMS)
- Customized substrate size up to 50x100mm
- Substrate temperature: from liquid nitrogen to 800°C
- Substrate linear movement for homogeneity
- Substrate biasing available
- Ar+hydrogen (70/30), oxigen, nitrogen gases for reactive sputtering
- Time resolved optical plasma emission spectroscopy for process control
- In-situ thickness measurement during deposition





Thermal evaporation cluster

- Edwards Auto 306
 - substrate size up to 6" (diameter)
 - controllable substrate temperature
 - 2 high temperature sources
 - 2 low temperature sources
- Thermal evaporation tool
 - low material consumption
 - up to 6 layers without breaking vacuum
 - substrate size up to 25 x 25 mm
 - low temperature/high temperature evaporation
 - controllable substrate temperature





Lithography

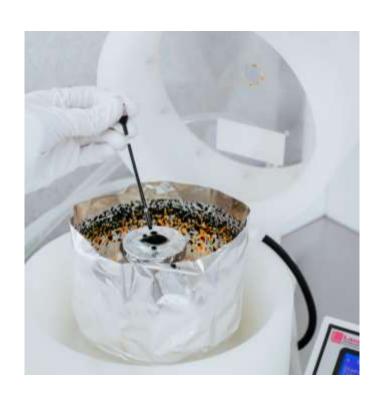
- Optical lithography (direct laser writer, mask aligner)
- E-beam lithography ultra high resolution
 Raith eLINE Plus (<10 nm)
- Various applications incl., micro lenses, photonic crystals, micro and nano structures



Wet casting of materials

- Spin coating (in glovebox, Ar atmosphere)
- Spray coating
- Blade casting
- Dip coating
- Langmuir

 Blodgett films
- Self assembling films
- Sol-gel process
- Ink-jet printing



Characterization

- Optical spectroscopy
- EPR spectroscopy
- Morphology analysis
- Electron microscopy (SEM, TEM)
- XRD & advances structure analysis
- Electrical & dielectric analysis
- Theoretical modelling



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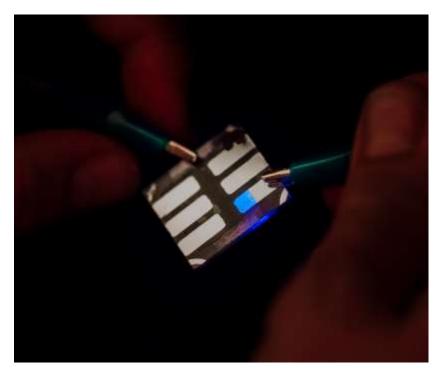
Examples

Organic thin films for OLED

Full cycle of OLED development

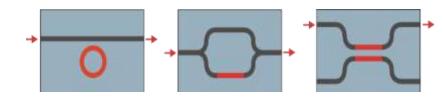
- Development
- Prototyping
- Characterization

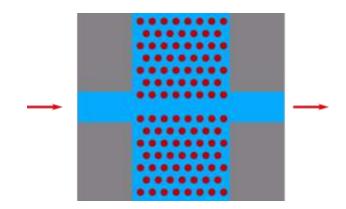
Organic thin films using vacuum evaporation and wet chemical coating



Optical waveguides

- Waveguide structures from SU-8 using lithography
- Electro-optical modulator devices
- Third-order nonlinear optical devices for light-to-light modulation

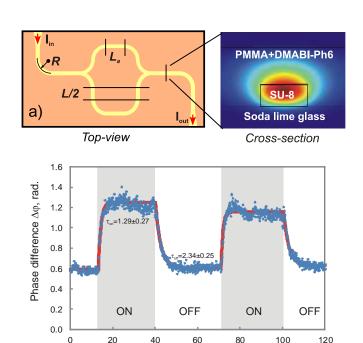




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Asymmetrical all-organic waveguide gas sensor

- Stable, light guiding optical waveguide core with high refractive index
- Cladding material that is sensitive to environment and changes its refractive index
- Waveguide device was tested using N₂ gas (OFF state) and N₂ and isopropanol mixture (ON state)
- Optical lithography, spin-coating used

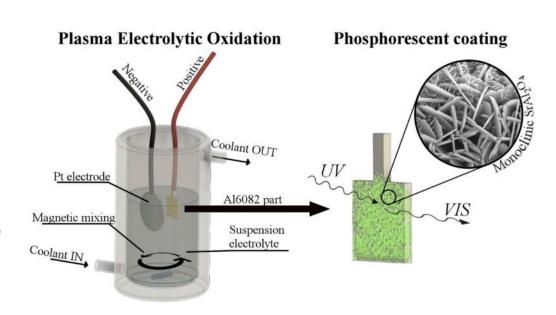


Time. s



Phosphorescent coatings on metals

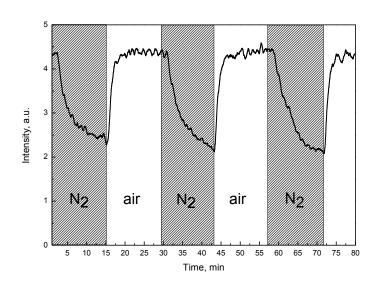
- Energy-efficient coating synthesis using plasma electrolytic oxidation (PEO)
- Long afterglow at room temperature
- Broad spectral distribution of luminescence in the visible range
- Road/emergency signs, road surface marking
- Direct coating on metal



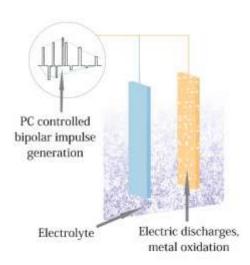


Oxigen sensing coatings

- Plasma electrolytic oxidation (PEO)
- Luminescent ZnO coatings



ZnO coating luminescence response to oxygen content

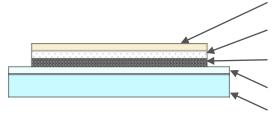


Plasma electrolytic oxidation

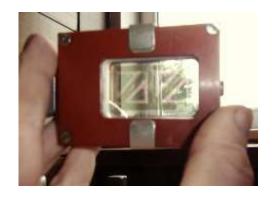


Electrochromic devices

- Electrochromic indication and information displays
- WO₃ as electrochromic material
- Thermal evaporation

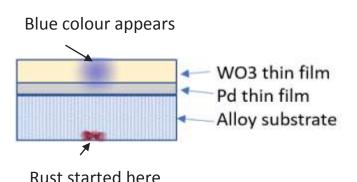


Semitransparent electrode – Au
 Ionic conductor – SiO_X
 Electrochromic layer – WO₃
 Transparent electrode – ITO
 Glass substrate



Visual rust indicator

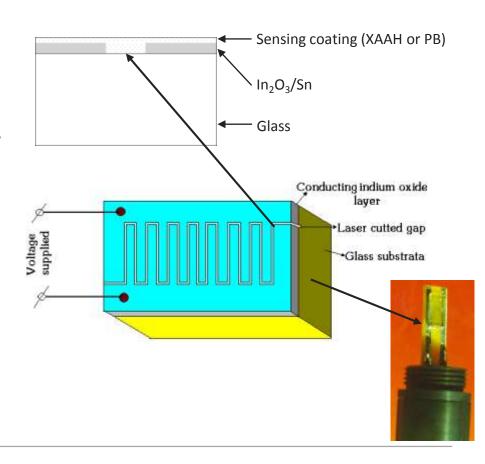
- Determination of the starting point of the rusting process inside the steel tube
- Hydrogen ions are formed in the rusting process, which diffuses very quickly into steel and reaches the surface coating
- Physical vapor deposition





Humidity/gas sensor

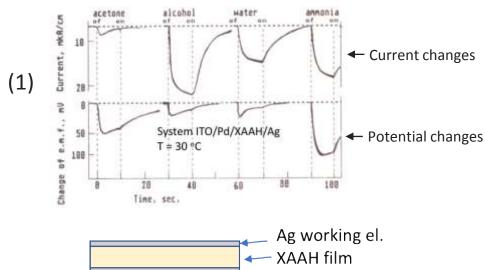
- Different coatings changes selectivity for gas sensing
 - XAAH (xerogel of antimonic acid hydrate) for ammonia,
 - PB (Prussian Blue) for ammonia or hydrogen
- Physical vapor deposition for PB
- Blade casting for XAAH

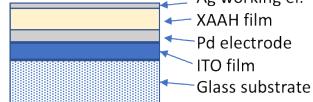


Antimonic acid hydrate as gas sensor

(2)

- XAAH layers are suitable materials for potentiometric and amperometric sensors, and it is possible to change selectivity by selecting definite material for a working electrode (1)
- Xerogel of Sb₂O₅·nH₂O (XAAH) was prepared by hydrolysis of SbCl₅ followed by slow drying which turned it into the xerogel film (2)

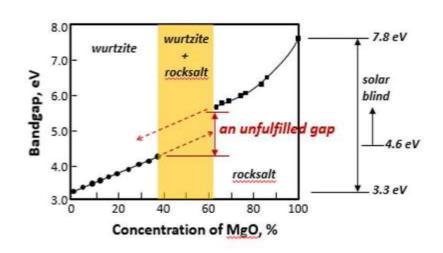






Thin films for solar-blind UV sensors

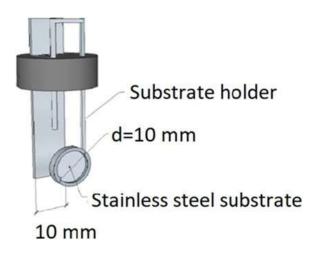
- ZnMgO materials with tunable band gap significantly enhance the ability of the sensor to detect signals at different energies simultaneously
- For ozone detection, detectors for water purification, determination of pollution levels in any biological agent
- In collaboration with National Sun Yat-sen University, Taiwan





Metal oxide (TiO₂, Fe₂O₃)-rGO composite as LIB anode

- Electrophoretic deposition or spray pyrolysis
- Used composite enhances charge capacity of battery

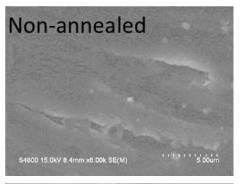


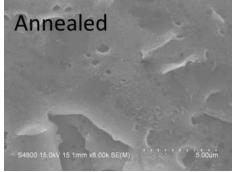
Scheme of electrophoretic deposition



LiFePO₄ – rGO composite as LIB cathode

- Magnetron sputtered LiFePO₄ thin films
- Used composite enhances charge capacity of thin film layer
- No need for binder
- Increases proportion of active material
- Electrode for thin film batteries suitable for flexible electronics

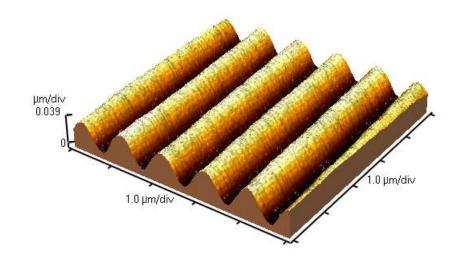






Holographic recording

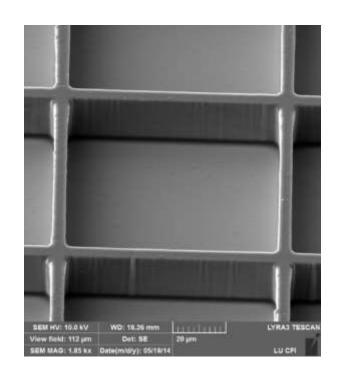
- Molecular glasses for holographic recording
- Surface-relief grating formation during holographic recording
- No chemical etching
- Electrochemical Ni-shim growing for printing



Our Partners

EuroLCDs - LCD development

- High voltage liquid crystal display development
- Infrared liquid crystal shutters
- Displays with transparent pixel walls
- Thin film resistance and I-V characteristics, surface morphology, dielectric breakdown, spin-coating deposition, spectral measurements, mask aligner







EuroLCDs

- Own research, industrialization & manufacturing facilities
- Development of customized solutions
- World's fastest optical shutter technology (< 0.1ms)
- Bi-stable low energy consumption display
- Manufacturing technology of smart (switchable) glass products







Sidrabe: development & implementation of thin film technologies

Customized vacuum coating systems

 Roll-to-roll systems for different materials, large 3D object in-line and batch coating systems, powder coating systems, cluster laboratory systems, systems for solar & battery applications







Sidrabe: customized R2R coaters

- AC/DC magnetron, e-beam & resistive evaporation, PECVD
- Single & double side single layers as well as multi-layer stacks
- Heating/cooling system of the process drums
- Multi-compartment chamber design
- Metal (magnetic & nonmagnetic) or ceramics target material
- Free web span during several runs, using reverse winding
- Low & smooth tension force profile for transportation











Groglass: functional glass coatings

- Anti-reflective & other high-performance coatings on glass and acryl
- Material and structure analysis (SEM-FIB, TEM) of thin coatings

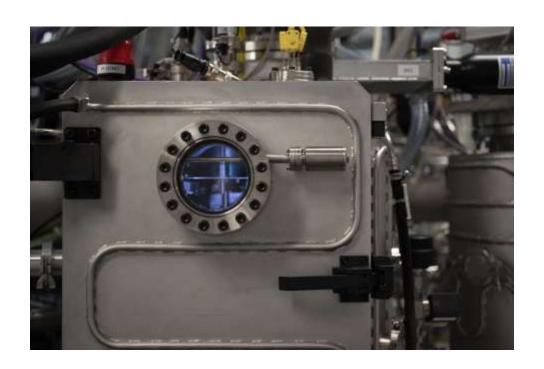






Schaeffler: anti-friction coatings

- Development of anti-friction coatings for automotive industry
- Characterization and analysis of coatings



Welcome to collaborate

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More on our expertise and case studies materize.com

Materize

Institute of Solid State Physics UL industry collaboration and innovation platform

- Single point of contact customer experience
- Talk with industry in business language
- Pro-active business / industry style projects management
- We make Scientific Expertise Beneficial to Business





Materize context

- Based in Latvia
- Strong national innovation eco-system player
- Strongest national materials research and innovation center
- 40 years in material science from complex oxides to organic semiconductors
- Deep expertise in spectroscopy
- Prototyping laboratory with 680 m2 of ISO class 7-8 cleanroom facility
- 200 employees / 100 PhD



Latvia Context

- Member of European Union, NATO, OECD, WTO
- EURO zone since Jan-2014
- Population 2M, Baltics 7M
- GDP annual growth **4-5**%
- 100+ direct flight connections, including Israel
- High stability and growth rating –
 by S&P, Moody's, World bank, IMF





What We Do



Prototyping and small scale production



Research and development of functional materials



Single point of contact



Theoretical material design and modelling



Environment for innovations